## Controlling the Sample Temperature in a Vacuum Thin Film Deposition Chamber.

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## Outline

# > Thin Films Research > Houghton Deposition Chamber > Heater Apparatus > Future Experiments







## **Applications of Thin Films**

- Electronics
- Optics
- Decoration





#### **Thin Film Introduction**







#### Silicon Substrate



Silicon Substrate with thin film layers

#### Thin Film Curvature due to Thermal Stress





**Turbo Pump** 

Ion Gauge

Ion Pump





![](_page_7_Picture_1.jpeg)

![](_page_8_Picture_1.jpeg)

![](_page_9_Figure_1.jpeg)

![](_page_10_Figure_1.jpeg)

![](_page_11_Figure_0.jpeg)

![](_page_12_Figure_0.jpeg)

![](_page_13_Figure_0.jpeg)

#### **Thermionic Emission**

- Electrons will be emitted from tungsten wire and accelerated towards substrate.
- Kinetic energy will be absorbed in the form of thermal energy.

![](_page_14_Figure_3.jpeg)

### **Future Experiments**

- Begin calibration testing this summer
- Perform depositions and experiments from start to finish without removing sample.
- Measure curvature at varying temperature and thickness of films using interferometer.
- Investigate concerns with heating and interferometer measurements.

## Questions?

![](_page_15_Picture_6.jpeg)